		SHEELLUFT
ATTY. DOCKET NO. SAEG115.002APC	APPLICATION NO. 10/502,511	
APPLICANT NAKATSUKA, et al.		
FILING DATE July 23, 2004	GROUP Unknown	

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)

FOREIGN PATENT DOCUMENTS								
EXAMINER		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSI	ATION
INITIAL							YES	NO
MAT	1.	JP 01-280465	11/10/89	Japan	,		Abstract	
MAT	2.	JP 09-241399	09/16/97	Japan			Abstract	
MAT	3.	JP 10-338615	12/22/98	Japan			Abstract	
MAT	4.	WO 98/55075	10/12/98	WIPO				
MAT	5.	WP 99/17303	09/30/97	WIPO				
MAT	6.	WO 01/45661 A2	12/11/00	WIPO	_			

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)					
	7. Shin_ichiro Hiraide, "Research regarding the chemical reforming of the silk fibroin film," Research Report of Information Technology Research Institute of Nagano Prefecture, No. 17, p. 53-54-2001					

H:\DOCS\KOA\KOA-5557.DOC 101804

EXAMINER	M. A.	Thexton